



Europäisches Patentamt
European Patent Office
Office européen des brevets

(11) Publication number:

**0 342 648
A2**

(12)

EUROPEAN PATENT APPLICATION

(21) Application number: 89108872.6

(51) Int. Cl.4: C08G 77/14 , G03F 7/10

(22) Date of filing: 17.05.89

(30) Priority: 18.05.88 JP 121426/88

(43) Date of publication of application:
23.11.89 Bulletin 89/47

(84) Designated Contracting States:
DE FR GB

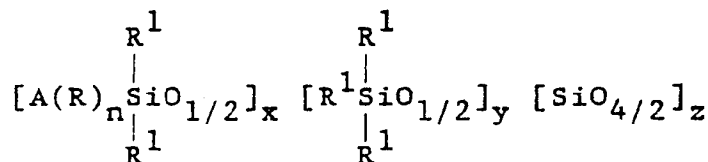
(71) Applicant: TORAY SILICONE COMPANY,
LIMITED
2-3-16, Muro-machi Nihonbashi
Chuo-ku Tokyo 103(JP)

(72) Inventor: Shirahata, Akihiko
6, 1-chome, Yushudai Nishi
Ichihara-shi Chiba Prefecture(JP)
Inventor: Fukutani, Yoshimi
6, 1-chome, Yushudai Nishi
Ichihara-shi Chiba Prefecture(JP)

(74) Representative: Spott, Gottfried, Dr. et al
Patentanwälte Spott und Puschmann
Sendlinger-Tor-Platz 11
D-8000 München 2(DE)

(54) Alkali-soluble organopolysiloxane.

(57) Alkali-soluble organopolysiloxanes useful in the alkali-developing resist materials for use in microprocesses in LSI device fabrication have the following general formula



where A is a hydroxyphenyl group; R is an alkylene group having 1 to 4 carbon atoms; n is zero or one; R¹ is an alkyl group having 1 to 4 carbon atoms; x and z are positive numbers; y is zero or a positive number; x, y, and z have values such that their ratios are $0.3 \leq (x + y)/z \leq 4$; and zero $\leq y/x \leq 5$.

EP 0 342 648 A2

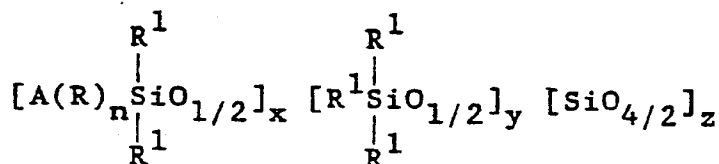
ALKALI-SOLUBLE ORGANOPOLYSILOXANE

Alkali-soluble organopolysiloxanes are already known in the form of the straight-chain, phenol-functional organopolysiloxane described in Japanese Patent Application Laid Open (Kokai or Unexamined) Number 61-256347 (256,347/86) and the polyorganosilsequioxane described in Japanese Patent Application Laid Open Number 62-96526 (96,526/87), both applications are the basis of U.S. Patent No. 4,745,169, issued May 17, 1988, to Sugiyama et al. In Japanese Patent Application Laid Open (Kokai) No. Sho 62-104,032 (104,032/87) to Hitachi KK, a diorganopolysiloxane having hydroxyphenylalkylene groups side chains and a hydroxyphenylalkyl polysilsesquioxane are known to be useful in alkali development-type organic silicon resist composed of alkali soluble siloxane polymer and a light or radiation sensitive dissolution inhibitor.

However, alkali-soluble organopolysiloxane having both the tetrafunctional siloxane unit and a hydroxyphenyl group-containing monofunctional triorganosiloxane unit in one and the same molecule has not been described up to now.

The present invention takes as its object the introduction of a novel alkali-soluble organopolysiloxane not heretofore described in the literature.

The aforesaid object is achieved by means of an alkali-soluble organopolysiloxane with a molecular weight of 500 to 500,000 and having the following general formula



in the formula, A is a hydroxyphenyl group; R is an alkylene group having 1 to 4 carbon atoms; n is zero or one; R¹ is an alkyl group having 1 to 4 carbon atoms; x and z are positive numbers; y is zero or a positive number; x, y, and z have values such that their ratios are $0.3 \leq (x + y)/z \leq 4$; and $0 \leq y/x \leq 5$.

To explain the preceding in greater detail, A in the above formula is the hydroxyphenyl group, and examples are the ortho-hydroxyphenyl group, the meta-hydroxyphenyl group, the para-hydroxyphenyl group, the 2,3-dihydroxyphenyl group, the 2,4-dihydroxyphenyl group, the 3,4-dihydroxyphenyl group, and the 3,5-dihydroxyphenyl group. Within the individual molecule, the group A may comprise only a single species, or it may comprise a combination of two or more different species. The group R comprises alkylene groups having 1 to 4 carbon atoms, and examples are methylene, ethylene, n-propylene, isopropylene, n-butylene, and isobutylene. Finally, n is zero or one.

R¹ is an alkyl group having 1 to 4 carbon atoms. Examples are methyl, ethyl, n-propyl, isopropyl, n-butyl, and isobutyl. Again, within the individual molecule R¹ may comprise only a single species, or may comprise a combination of two or more different species.

Furthermore, x and z are positive numbers, y is zero or a positive number, and it is necessary that $0.3 \leq (x + y)/z \leq 4$ and that $0 \leq y/x \leq 5$. When x, y, and z fall outside these ranges, synthesis becomes difficult and alkali solubility is not obtained. Furthermore, when x, y, and z satisfy $0.4 \leq (x + y)/z \leq 1.2$ and $0 \leq y/x \leq 5$, the organopolysiloxane of the present invention will be a solid at room temperature.

The molecular weight is to be 500 to 500,000 because synthesis is difficult outside this range.

Any of the following may be bonded to the tetrafunctional siloxane unit with the formula

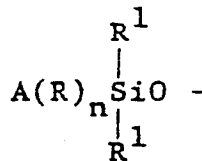


in the organopolysiloxane of the present invention: other tetrafunctional siloxane units with the formula



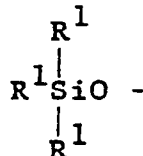
monofunctional siloxane units with the following general formula

5



10 A, R, R¹, and n in the formula are defined as above, and monofunctional siloxane units with the following general formula

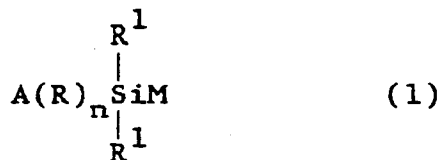
15



20 R¹ is defined as above. In addition, the organopolysiloxane of the present invention may also contain minor quantities of hydroxyl groups, alkoxy groups, and halogen atoms, etc., as residues from the synthesis process.

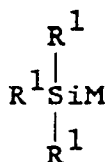
25 The alkali-soluble organopolysiloxane of the present invention can be prepared by the cohydrolysis and condensation reactions of x moles of a hydrolyzable group-containing organosilane with the following general formula

30



35 in formula (1), A, R, R¹, and n are defined as above, and M is a hydrolyzable group, y moles of a hydrolyzable group-containing organosilane with the following general formula

40

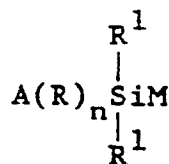


45

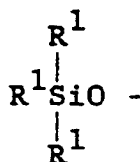
R¹ and M are defined as above, and z moles of a hydrolyzable silane with the following general formula SiM₄

50 M in the formula is defined as above, wherein x, y, and z are defined as above. Synthesis may also be carried out by analogous cohydrolysis and condensation reactions, but replacing the organosilane with formula (1) with the corresponding compound in which the hydroxyl group of the hydroxyphenyl moiety is protected by an alkyl group such as methyl, ethoxyethyl, or t-butyl; an acyl group such as acetyl; or a trialkylsilyl group such as trimethylsilyl or t-butyldimethylsilyl and the hydrolyzable group-containing organosilane has the following general formula

55



in the formula, A, R, R¹, and n are defined as above, and M is a hydrolyzable group. Furthermore, in the case of protection with a trialkylsilyl group, this trialkylsilyl group undergoes hydrolysis and is introduced into the organopolysiloxane of the present invention in the form of the monofunctional siloxane unit with the general formula



R¹ is defined as above.

Examples of the hydrolyzable group M in the above formulas are halogen atoms such as the chlorine atom and bromine atom; alkoxy groups such as methoxy, ethoxy, isopropoxy, and methoxyethoxy; and acyloxy groups such as acetoxo.

Solvent may be used during cohydrolysis, such as aromatic hydrocarbon solvents such as benzene, toluene, and xylene; alcohol solvents such as methanol and ethanol; ketone solvents such as acetone; and chlorinated hydrocarbon solvents. Furthermore, an acid or alkali catalyst may be used in order to promote the cohydrolysis and condensation reactions. Examples of the former are hydrochloric acid, sulfuric acid, phosphoric acid, nitric acid, and acetic acid, and examples of the latter are sodium hydroxide, potassium hydroxide, lithium hydroxide, ammonia, and amines.

Merely by varying the molar ratio between the monofunctional siloxane units and tetrafunctional siloxane units, it is possible freely to adjust various properties of the organopolysiloxane of the present invention, for example, the molecular weight, softening point, quantity of hydroxyphenyl group, alkali solubility, etc. The organopolysiloxane of the present invention is soluble in aqueous alkali solutions such as aqueous sodium hydroxide and aqueous tetramethylammonium hydroxide, and is also soluble in various organic solvents such as hydrocarbon solvents, aromatic hydrocarbon solvents, chlorinated hydrocarbon solvents, alcohol solvents, ether solvents, amide solvents, ketone solvents, ester solvents, and Cellosolve solvents. Accordingly, one can contemplate practical application in, inter alia, alkali-developing resist materials for use in microprocesses in LSI device fabrication.

The following examples are presented for illustrative purposes and should not be construed as limiting the invention which is properly delineated in the claims. The present invention is further explained by means of the following examples, in which Me = methyl.

REFERENCE EXAMPLE 1

(1) Synthesis of m-isopropenylphenyl trimethylsilyl ether

134.2 g (1.0 mol) m-isopropenylphenol was placed in a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer. While stirring and heating at 70 degrees Centigrade, 96.8 g (0.6 mol) hexamethyldisilazane was dripped in from the addition funnel, and ammonia was simultaneously evolved. After the completion of the addition, the reaction was additionally stirred for approximately 2 hours at 70 degrees Centigrade. Distillation in vacuo afforded 202 g (0.98 mol) of the target material. The yield was 98%. The properties of the product, as reported below, confirmed it to be m-isopropenylphenyl trimethylsilyl ether.

boiling point: 85 degrees Centigrade/4 mmHg

NMR delta (ppm): 0.61 (s, 9H), 2.44 (s, 3H), 5.21 (m, 1H), 5.54 (m, 1H), 6.8 to 7.8 (m, 4H)

(2) Synthesis of 1-(chlorodimethylsilyl)-2-(m-trimethylsiloxyphenyl)propane

5

The following were added to a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer: 165 g (0.8 mol) m-isopropenylphenyl trimethylsilyl ether from step (1), 0.2 g 4-methoxyphenol, and 100 ppm as platinum of 2 weight% isopropanolic chloroplatinic acid solution. While stirring and heating at 50 to 60 degrees Centigrade, 83.5 g (0.88 mol) dimethylchlorosilane was dripped in from the addition funnel over 5 hours. After the completion of the reaction, distillation in vacuo afforded 202 g (0.67 mol) of the target material. The yield was 84%. Some properties of this product are reported below.

boiling point: 115 degrees Centigrade/2 mmHg

NMR delta (ppm): 0.25 (s, 3H), 0.27 (s, 3H), 0.61 (s, 9H), 1.1 to 1.5 (m, 5H), 2.8 to 3.2 (m, 1H), 6.5 to 7.3 (m, 4H)

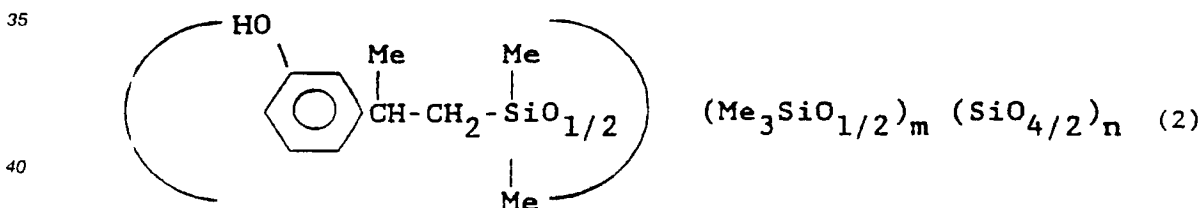
15

EXAMPLE 1

The following were charged to a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer: 120.4 g (0.4 mol) of the 1-(chlorodimethylsilyl)-2-(m-trimethylsiloxyphenyl)propane obtained in step (2) of Reference Example 1, 208.3 g (1.0 mol) tetraethoxysilane, and 100 g toluene. While stirring and heating at 70 degrees Centigrade, a mixture of 60 g water, 40 g concentrated hydrochloric acid, and 20 g ethanol was dripped in over approximately 1 hour.

After the completion of addition, heating under reflux at 75 degrees Centigrade was continued for 4 hours. 250 g water was then added, and 2 layers separated upon standing. The lower, polymer layer was taken off, and the upper layer was extracted with 200 g toluene. The polymer and toluene layers were then combined. This was placed in a flask equipped with a graduated water separator, and the water and ethanol were azeotropically distilled out. 0.10 g potassium hydroxide was added, and dehydration was continued for 4 hours and the residual silanol was condensed. Cooling, neutralization of the potassium hydroxide with trimethylchlorosilane, filtration, and concentration, provided 147 g of an organopolysiloxane according to the present invention (yield = 85%).

The properties of this product, as reported below, confirmed it to be an organopolysiloxane with the following structure



in the formula, $l : m : n = 0.4 : 0.4 : 1$.

45 molecular weights (GPC, chloroform solvent, calibrated with polystyrene standard):

\overline{M}_w (weight-average molecular weight) = 1.3×10^3

\overline{M}_n (number-average molecular weight) = 1.1×10^3

softening point: 80 to 85 degrees Centigrade

^1H NMR delta (ppm): -0.4 to 0.4 (br, 15H), 0.7 to 1.4 (br, 6H), 2.5 to 3.1 (br, 6H), 6.2 to 7.2 (br, 4H)

50 ^{29}Si NMR delta (ppm): -115 to -103 (br, 0.93Si), -103 to -98 (br, 0.07Si), 9 to 16 (br, 0.63Si)

^{13}C NMR delta (ppm): 1 (s, 4.5C), 25 (s, 1C), 28 (s, 1C), 36 (s, 1C), 114 (s, 1C), 119 (m, 2C), 129 (s, 1C), 149 to 157 (m, 2C)

IR ν (cm^{-1}): 3450 (br), 2970, 2900, 1600, 1490, 1450, 1250, 1080 (br), 840, 760, 700

55 Organopolysiloxane polymers according to the present invention were similarly obtained by charging the 1-(chlorodimethylsilyl)-2-(m-trimethylsiloxyphenyl)propane obtained in step (2) of Reference Example 1, tetraethoxysilane, and trimethylchlorosilane to the reaction at the proportions given in Table 1. In Table 1, x represents moles of 1-(chlorodimethylsilyl)-2-(m-trimethylsiloxyphenyl)propane; y represents moles of trimethylchlorosilane; and z represents moles of tetraethoxysilane. Some properties of the products are also

reported in Table 1.

TABLE 1

MOLAR RATIO OF CHARGE					\bar{M}_w	SOFTENING POINT, °C	1:m:n in Formula (2)				
x		y		z							
0.40	:	0	:	1	1.3×10^3	80 to 85	0.4	:	0.4	:	1
0.35	:	0	:	1	3.4×10^3	190 to 200	0.35	:	0.35	:	1
0.30	:	0.20	:	1	1.2×10^3	75 to 80	0.3	:	0.5	:	1

The products were soluble in organic solvents such as methanol, ethanol, tetrahydrofuran, toluene, dimethylformamide, methyl isobutyl ketone, isoamyl acetate, hexane, and carbon tetrachloride, and were also soluble in aqueous sodium hydroxide and aqueous tetramethylammonium hydroxide.

REFERENCE EXAMPLE 2

(1) Synthesis of m-acetoxyisopropenylbenzene

250 g (1.86 mol) m-isopropenylphenol and 15 mL (0.19 mol) pyridine were placed in a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer. While stirring with cooling on a water bath, 200 mL (2.12 mol) acetic anhydride was dripped in. The reaction mixture was then diluted with ether and washed with water to neutrality. Drying and distillation afforded 310 g (1.76 mol) of the target material. The yield was 94%. The properties of this product are reported below.

boiling point: 100 degrees Centigrade/4 mmHg

NMR delta (ppm): 1.97 (s, 3H), 2.00 (s, 3H), 4.90 (m, 1H), 5.19 (m, 1H), 6.65 to 7.15 (m, 4H)

(2) Synthesis of 1-(chlorodimethylsilyl)-2-(m-acetoxyphenyl)-propane

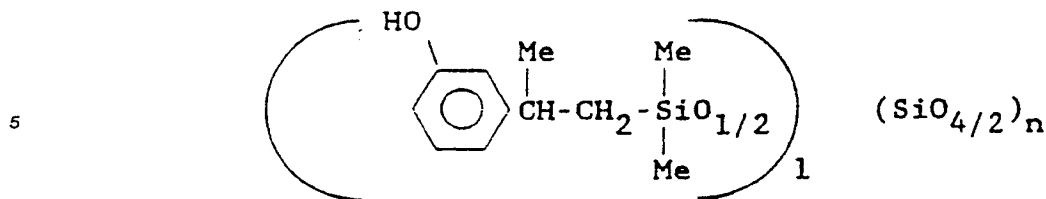
The following were charged to a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer: 100 g (0.57 mol) m-acetoxyisopropenylbenzene as prepared in step (1) of Reference Example 2, sufficient 2 weight% isopropanolic chloroplatinic acid solution to give approximately 100 ppm as platinum, and 0.2 g 4-methoxyphenol. While stirring and heating at 80 degrees Centigrade, 70 g (0.74 mol) dimethylchlorosilane was dripped in from the addition funnel. After completion of the reaction, distillation in vacuo afforded 115 g (0.42 mol) of the target material. The yield was 75%. The properties of this product are reported below.

boiling point: 113 degrees Centigrade/2 mmHg

NMR delta (ppm): 0.14 (s, 6H), 1.16 (s, 2H), 1.26 (s, 3H), 2.12 (s, 3H), 2.65 to 3.30 (m, 1H), 6.55 to 7.30 (m, 4H)

EXAMPLE 2

The following were charged to a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer: 67.7g (0.25 mol) of the 1-(chlorodimethylsilyl)-2-(m-acetoxyphenyl)propane as prepared in step (2) of Reference Example 2, 104.2 g (0.5 mol) tetraethoxysilane, and 50 g toluene. While stirring and heating at 70 degrees Centigrade, a mixture of 30 g water, 20 g concentrated hydrochloric acid, and 10 g ethanol was dripped in over approximately 1 hour. Separation, dehydration, and condensation were carried out as in Example 1 to afford 77.5 g of an organopolysiloxane according to the present invention. The yield was 96%. The properties of this product, as reported below, confirmed it to be an organopolysiloxane with the following structure.



10 in the formula, $l : n = 0.5 : 1$.

softening point: 150 to 160 degrees Centigrade

¹HNMR delta (ppm): -1.0 to 0.0 (br, 6H), 0.0 to 1.2 (br, 5H), 2.0 to 2.9 (br, 1H), 5.9 to 6.8 (br, 4H)

²⁹SiNMR delta (ppm): -115 to -105 (br, 0.90Si), -105 to -95 (br, 0.10Si), 10 to 20 (br, 0.59Si)

molecular weights:

15 $\bar{M}_w = 5.6 \times 10^3$

$\bar{M}_n = 3.2 \times 10^3$

This product was soluble in methanol, tetrahydrofuran, dimethylformamide, methyl isobutyl ketone, and isoamyl acetate, but was poorly soluble in hexane, carbon tetrachloride, chloroform, toluene, etc. It was also soluble in aqueous sodium hydroxide and aqueous tetramethylammonium hydroxide.

20

REFERENCE EXAMPLE 3

25 Synthesis of 1-(chlorodimethylsilyl)-2-(p-tert-butoxyphenyl)-ethane

The following were charged to a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer: 176.3 g (1 mol) p-tert-butoxystyrene, 0.2 g 4-methoxyphenol, and sufficient 2 weight% isopropanolic chloroplatinic acid solution to give approximately 100 ppm as platinum. While stirring and heating at 50 to 60 degrees Centigrade, 104 g (1.1 mol) dimethylchlorosilane was dripped in over 5 hours from the addition funnel. After completion of the reaction, distillation *in vacuo* afforded 203 g (0.75 mol) of the target material. The yield was 75%. The properties of this product are reported below.

boiling point: 110 degrees Centigrade/0.3 mmHg

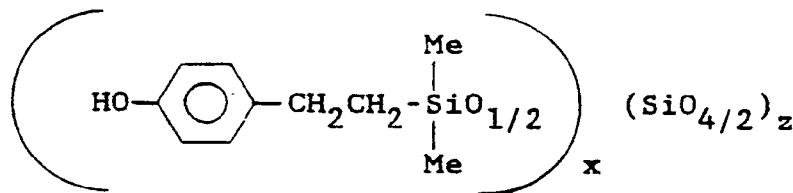
35 NMR delta (ppm): 0.15 (s, 6H), 0.93 to 1.43 (m, 2H), 1.27 (s, 9H), 2.25 to 2.83 (m, 2H), 6.7 to 7.3 (m, 4H)

35

EXAMPLE 3

The following were charged to a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer: 95 g (0.35 mol) of the 1-(chlorodimethylsilyl)-2-(p-tert-butoxyphenyl)ethane as prepared in Reference Example 3, 104.2 g (0.5 mol) tetraethoxysilane, and 50 g toluene. While stirring and heating at 70 degrees Centigrade, a mixture of 30 g water and 30 g hydrochloric acid was dripped in over approximately 2 hours. Heating under reflux at approximately 75 degrees Centigrade was continued for an additional 4 hours after the completion of addition. 100 g water was then added, and the reaction mixture separated into two layers upon standing. The lower layer (polymer layer) was taken off, 100 g toluene was added to it, and this mixture was placed in a flask equipped with a graduated water separator. The water and ethanol were azeotropically removed, 0.10 g potassium hydroxide was added, and dehydration was continued for 4 hours and the residual silanol was condensed. Cooling to room temperature, neutralization by the addition of trimethylchlorosilane, filtration, and concentration afforded 82 g of an organopolysiloxane of the present invention. The yield was 86%. This product was soluble in methanol, tetrahydrofuran, dimethylformamide, and methyl isobutyl ketone, but poorly soluble in hexane, carbon tetrachloride, toluene, etc. It was soluble in aqueous sodium hydroxide and aqueous tetramethylammonium hydroxide. The properties of this product are reported below.

55



in the formula, $x : z = 0.7 : 1$.

softening point: 90 to 100 degrees Centigrade

molecular weights:

$$\overline{M}_w = 2.0 \times 10^3$$

$$\overline{M}_n = 1.7 \times 10^3$$

^1H NMR delta (ppm): -0.5 to 0.5 (br, 6H), 0.5 to 1.3 (br, 2H), 2.3 to 3.0 (br, 2H), 6.5 to 7.4 (br, 4H)

^{29}Si NMR delta (ppm): -115 to -105 (br, 0.87Si), -105 to -95 (br, 0.13Si), 10 to 20 (br, 0.75Si)

REFERENCE EXAMPLE 4

Synthesis of p-methoxyphenyldimethylchlorosilane

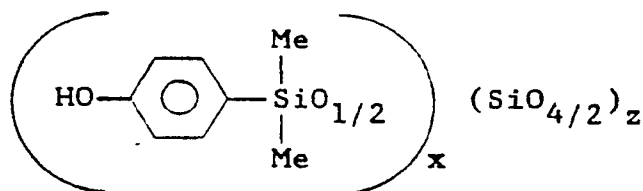
The following were placed in a dry four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer under a nitrogen blanket: 23.3 g (1.0 mol) powdered magnesium, 129.1 g (1.0 mol) dimethyldichlorosilane, and 200 mL tetrahydrofuran. A small quantity of iodine was added in order to activate the magnesium. Then, while cooling the flask to below 10 degrees Centigrade, a mixture of 142.6 g (1.0 mol) p-chloroanisole and 300 mL tetrahydrofuran was dripped in from the addition funnel with stirring over 5 hours. The reaction mixture was aged by heating under reflux for 2 hours, the precipitate was removed by suction filtration, and the filtrate was distilled to give 122 g (0.61 mol) product. The yield was 61%. The properties of this product are reported below.

boiling point: 100 to 104 degrees Centigrade/3 mmHg

NMR delta (ppm): 0.70 (s, 6H), 3.75 (s, 3H), 6.8 to 7.5 (m, 4H)

EXAMPLE 4

The following were placed in a four-neck flask equipped with a stirrer, reflux condenser, addition funnel, and thermometer: 70.3 g (0.35 mol) of the p-methoxyphenyldimethyl-chlorosilane as prepared in Reference Example 4, 104.2 g (0.5 mol) tetraethoxysilane, and 50 g toluene. Hydrolysis, layer separation, dehydration, and condensation as in Example 3 afforded 80 g of a polymer containing methyl-protected phenol. The yield was 88%. In order to remove the protective group, the obtained polymer was dissolved in chloroform in a flask under nitrogen, iodotrimethylsilane was added at 1.5 equivalents based on the methoxy group, and the reaction was stirred for 3 hours at room temperature. Methanol was then added, followed by stirring for an additional 2 hours. This was followed by successively washing with aqueous sodium bisulfite, aqueous sodium bicarbonate, and ion-exchanged water, drying, filtration, and concentration, thus to yield up an organopolysiloxane of the present invention. The properties of this product, as reported below, confirmed it to be an organopolysiloxane with the following structure.



in the formula, $x : z = 0.7 : 1$.

softening point: 95 to 105 degrees Centigrade

molecular weights:

$$\overline{M}_w = 2.0 \times 10^3$$

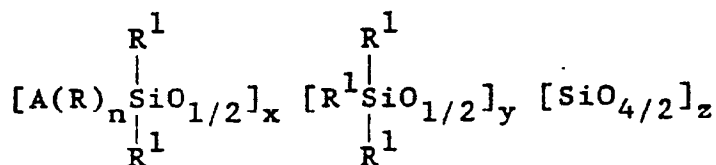
$$\overline{M}_n = 1.7 \times 10^3$$

^1H NMR delta (ppm): 0.4 to 1.0 (br, 6H), 6.7 to 7.5 (br, 4H)

^{29}Si NMR delta (ppm): -115 to -105 (br, 0.85Si), -105 to -95 (br, 0.15Si), -10 to 5 (br, 0.72Si)

10 Claims

1 Alkali-soluble organopolysiloxane with a molecular weight of 500 to 500,000 and having the following general formula



in the formula, A is a hydroxyphenyl group; R is an alkylene group having 1 to 4 carbon atoms; n is zero or one; R¹ is an alkyl group having 1 to 4 carbon atoms; x and z are positive numbers; y is zero or a positive number; x, y, and z have values such that their ratios are $0.3 \leq (x + y)/z \leq 4$; and zero $\leq y/x \leq 5$.

19



Europäisches Patentamt
European Patent Office
Office européen des brevets



11 Publication number:

0 342 648 A3

12

EUROPEAN PATENT APPLICATION

21 Application number: 89108872.6

51 Int. Cl.⁵: C08G 77/14, G03F 7/10

22 Date of filing: 17.05.89

30 Priority: 18.05.88 JP 121426/88

43 Date of publication of application:
23.11.89 Bulletin 89/47

94 Designated Contracting States:
DE FR GB

98 Date of deferred publication of the search report:
30.01.91 Bulletin 91/05

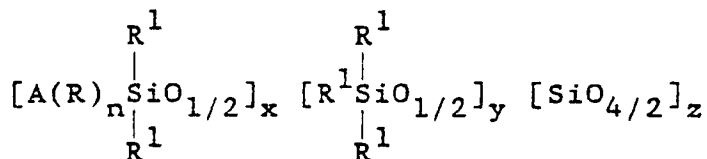
71 Applicant: TORAY SILICONE COMPANY,
LIMITED
2-3-16, Muro-machi Nihonbashi
Chuo-ku Tokyo 103(JP)

72 Inventor: Shirahata, Akihiko
6, 1-chome, Yushudai Nishi
Ichihara-shi Chiba Prefecture(JP)
Inventor: Fukutani, Yoshimi
6, 1-chome, Yushudai Nishi
Ichihara-shi Chiba Prefecture(JP)

74 Representative: Spott, Gottfried, Dr. et al
Patentanwälte Spott und Puschmann
Sendlinger-Tor-Platz 11
D-8000 München 2(DE)

54 Alkali-soluble organopolysiloxane.

57 Alkali-soluble organopolysiloxanes useful in the alkali-developing resist materials for use in microprocesses in LSI device fabrication have the following general formula



where A is a hydroxyphenyl group; R is an alkylene group having 1 to 4 carbon atoms; n is zero or one; R¹ is an alkyl group having 1 to 4 carbon atoms; x and z are positive numbers; y is zero or a positive number; x, y, and z have values such that their ratios are 0.3 ≤ (x + y) / z ≤ 4; and zero ≤ y / x ≤ 5.

EP 0 342 648 A3



European
Patent Office

EUROPEAN SEARCH REPORT

Application Number

EP 89 10 8872

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
P,Y	EP-A-0 294 277 (SHIN-ETSU CHEMICAL CO., LTD.) " claim 1 "	1	C 08 G 77/14 G 03 F 7/10

Y,D	US-A-4 745 169 (SUGIYAMA ET AL.) " claims "	1	

Y	GB-A-1 203 071 (GENERAL ELECTRIC COMPANY) " claims "	1	

A,D	PATENT ABSTRACTS OF JAPAN vol. 11, no. 309 (E-547)(2756) 8 October 87, & JP-A-62 104032 (HITACHI LTD.) 14 May 1987, " the whole document "	1	

A	GB-A-1 022 742 (DOW CORNING CORPORATION) " claims 1, 2, 11-16 "	1	

			TECHNICAL FIELDS SEARCHED (Int. Cl.5)
			C 08 G G 03 F
The present search report has been drawn up for all claims			
Place of search		Date of completion of search	Examiner
The Hague		29 November 90	HOLLENDER C.J.F.
CATEGORY OF CITED DOCUMENTS			
X: particularly relevant if taken alone		E: earlier patent document, but published on, or after the filing date	
Y: particularly relevant if combined with another document of the same category		D: document cited in the application	
A: technological background		L: document cited for other reasons	
O: non-written disclosure		-----	
P: intermediate document		&: member of the same patent family, corresponding document	
T: theory or principle underlying the invention			